ADSORPTION AND DISSOCIATION OF H$_2$S ON V(110), Pd(111) AND Pd OVERLAYER ON V(110) SURFACES: A DENSITY FUNCTIONAL THEORY STUDY

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Abstract
An interesting prospective pseudomorphic overlayer on bcc surface material as implemented in Pd pseudomorphic overlayer on V(110) surface has been introduced in the frame work of first-principles calculation. Adsorption and decomposition of H$_2$S molecule were calculated on this overlayer structure. In comparison, we calculated them on their bare V(110) and Pd(111) surfaces. It was found that Pseudomorphic overlayer surface structure weakened the adsorption energy of H$_2$S, SH, S and H compared to its bare Pd(111) and V(110) surfaces. Furthermore, Pd/V(110) surface was found to have higher activation energy barrier for H$_2$S and SH dissociation than its bare Pd(111) and V(110) do. Pd/V(110) surface is predicted to be a promising catalyst membrane used in gas-shift reactor technology because besides its advantage to absorb hydrogen with very high permeation coefficient, sulfur atom is predicted to be adsorbed in a limited amount.

Keywords: vanadium, palladium, hydrogen sulfide, dissociative adsorption, density functional calculation

Introduction
Hydrogen is the most promising energy carrier that can be produced from a wide variety of feedstock. Recently, the technology of hydrogen production primarily is being developed by three major methods; thermal, chemical, and biological methods. Each of them has their own advantages including high purity product, low cost production, non-reformer requirement, etc. Until today, thermal method is still the most reliable and dependable way to produce high purity hydrogen in large quantities. This advantage is required in many industrial chemical production and future energy carrier as a replacement of electricity that nowadays has been well developed and widely used.
Thermal process which use coal gasification and is combined with the reforming process is a particular promising technology for the production of ultrahigh purity hydrogen up to 99.99% efficiency with near-zero greenhouse gas emissions (Young, 1963). This process is possible by directing streams of the mixtures gas produced from gasification against barriers membrane. The barriers are permeable to a particular selected component gas but impermeable to other gases (McKinley, 1966). Using a dense metal such as Palladium (Pd) as the barrier membrane, it is possible to implement such process into hydrogen production process because Pd is permeable enough to separate hydrogen from the contaminant gases such as CO, CO$_2$, etc. This way, one can both get the benefit of the hydrogen and discard the contaminants in a proper way.

However H$_2$S, the most common impurities in fossil fuel based feed streams, is possible to create sulfur poisoning which greatly affects the catalytic activity of Pd membrane (Hughes, 2000). At high coverage sulfur adlayer ($\theta_s > 0.5$), hydrogen is unfavorable to be adsorbed on Pd surface, which will lead to reduction in hydrogen permeation through palladium membrane (Wilke et al., 1995). Furthermore, being one of the most expensive precious metals, palladium became a big challenge for commercial practicality.

It is known that body-centered cubic metals such as Vanadium (V) and Niobium (Nb) have hydrogen permeation coefficient up to 15 times higher and much more inexpensive than face-centered cubic Palladium (Uemiya, 2004 and Adhikari, 2006). However, V and Nb are easily to be oxidized, so that the dissociation of a hydrogen molecule on the metal surface is often disturbed by the formation of an oxide layer (Uemiya, 2004). Recently, this problem can be minimized by coating the surface with a palladium overlayer (Ozaki et al., 2003 and Wu et al., 1995). Ozaki et al. reported that electroless-palladium-plated V and V-15Ni with a pretreatment of oxide removal possessed satisfactory durability and hydrogen-permeability (Ozaki et al., 2003).

Palladium overlayer is such an interesting atomic structure which its electronic properties can be dramatically changed due to the interfacial interaction. For example, Rodriguez et al. reported that admetal monolayer have electron densities that vary significantly from those of the corresponding pure metals; a pseudomorphic Pd adlayer on top of Ta(110), W(110), Ru(0001), and Re(0001) substrates appears to chemisorb CO in the same way as does a pure Ag surface (Rodriguez et al., 1992). In addition, Wieland et al. showed experimentally that a palladium-coated vanadium membrane (sandwich-like coating) had the highest permeation rate compared with PdAg and PdCu alloys (Wieland et al., 2002).

Studying the behavior of H$_2$S on Pd and other metal surfaces has been so much reported (Alfonso et al., 2005, Alfonso et al., 2008, Spencer et al, 2008, and Hyman et al., 2007). Such study is important in order to understand the reasons for the sulfur poisoning at many reforming process of the mixture gas. However, to the best of our knowledge, adsorption properties and dissociation mechanisms of H$_2$S molecule on V(110) and Pd overlayer on V(110) surfaces are still remain unclear.

To study the mechanism of H$_2$S adsorption and dissociation on Pd/V(110) surface, we have carried out a set of calculations based on the density functional theory (DFT) on the adsorptions of H$_2$S, SH,
and S on the bare V(110) and Pd(111) surfaces and on Pd/V(110) surface. The details of the methods used and the results of these calculations are presented below.

**Theoretical Frameworks**

**FCC and BCC Bulk and Surface Structures**

Vanadium is a body centered cubic (bcc) crystal structure which consists of one atom in its primitive cell. With \( a \) is a lattice constant, bcc’s primitive lattice vectors are:

\[
\begin{align*}
A(1) &= -\frac{1}{2}a \ X + \frac{1}{2}a \ Y + \frac{1}{2}a \ Z \\
A(2) &= +\frac{1}{2}a \ X - \frac{1}{2}a \ Y + \frac{1}{2}a \ Z \\
A(3) &= +\frac{1}{2}a \ X + \frac{1}{2}a \ Y - \frac{1}{2}a \ Z
\end{align*}
\]

Palladium is a face centered cubic (fcc) crystal structure which one atom in its primitive cell. With \( a \) is a lattice constant, fcc’s primitive lattice vectors are:

\[
\begin{align*}
A(1) &= \frac{1}{2}a \ Y + \frac{1}{2}a \ Z \\
A(2) &= \frac{1}{2}a \ X + \frac{1}{2}a \ Z \\
A(3) &= \frac{1}{2}a \ X + \frac{1}{2}a \ Y
\end{align*}
\]

Metal surfaces were constructed from their bulk structures. Miller indices of (110) and (111) surfaces were selected for vanadium and palladium metals respectively because these respective surfaces are their most dense surfaces.

![Figure 1](image1.png)

**Figure 1.** (a) Fcc(111) and (b) Bcc(110) Surfaces

Figure 1 shows the configuration of fcc(111) and bcc(110) surfaces. Atom A, B, and C in Figure 1 (a) is the primitive atoms which is belong to the first, second, and third layers respectively. For fcc(111) surface there are three different primitive atoms, so that there would be two different hollow sites. And for bcc(110) surface there are two different primitive atoms, so that there would be one hollow site. The arrowed lines showed in Figure 1 is the primitive lattice vectors of fcc(111) and bcc(110) surfaces.
The Slab Model

Figure 2. Slab model of (a) V(110) (b) Pd(111) (c) Pd/V(110)

The (110) and (111) structures is modeled by slab geometry. Slab model is composed of three metal layers for V(110) and Pd(111) surfaces and four metal layers for Pd/V(110) surface and separated by 10 Å of vacuum space as shown in Figure 2. A 3 × 3 unit cell is used to construct a metal layer, which means each layer consists of 9 metal atoms. Adsorbate species of H₂S, SH, S, and H are placed on one side of the studied metal surfaces at coverage $\theta = 1/9$ monolayer (one molecule or atom above nine metal atoms of a surface).

Vienna Ab initio Simulation Package (VASP)

VASP is a package for performing ab initio quantum-mechanical molecular dynamics (MD) using pseudopotentials and a plane wave basis set. The approach implemented in VASP is based on a finite-temperature local-density approximation and an exact evaluation of the instantaneous electronic ground state at each MD-step using efficient matrix diagonalization schemes and an efficient Pulay mixing. These techniques avoid all problems occurring in the original Car-Parrinello method which is based on the simultaneous integration of electronic and ionic equations of motion. The interaction between ions and electrons is described using ultrasoft Vanderbilt pseudopotentials (US-PP) or the projector augmented wave (PAW) method. Both techniques allow a considerable reduction of the necessary number of plane-waves per atom for transition metals and first row elements. Forces and stress can be easily calculated and are used to relax atoms into their instantaneous ground state.

Climbing Image Nudge Elastic Band (CI-NEB)

In order to find the activation energy barrier of H₂S dissociation process, the most maximum energies along the reaction path have to be obtained. The atomic configuration with this energy is referred to as transition state, while the other maxima and minima are referred to as saddle points.

The nudged elastic band (NEB) is a method for finding saddle points and minimum energy paths (MEP) between known reactants and products (end points). The method works by optimizing a number of intermediate images along the reaction path. Each image finds the lowest energy possible while
maintaining equal spacing to neighboring images. This constrained optimization is done by adding spring forces along the band between images and by projecting out the component of the force due to the potential perpendicular to the band. This force projection is referred to as nudging.

While the NEB method gives a discrete representation of the MEP, the energy of saddle points needs to be obtained by interpolation. However unfortunately, when the energy barrier is too narrow compared with the length of the MEP, few images land in the neighborhood of the saddle point and the interpolation can be inaccurate. The red circle in Figure 3 is the example of this phenomenon where an intermediate minimum is located along the MEP. In fact, it turns out that this minimum is deeper than the chemisorbed state at the 0.0 end points.

![Figure 3. Comparison of NEB and CI-NEB (Henkelman et al., 2000)](image)

The climbing image NEB (CI-NEB) is a small modification to the NEB method in which the highest energy image is driven up to the saddle point. This image does not feel the spring forces along the band. Instead, the true force at this image along the tangent is inverted. In this way, the image tries to maximize its energy along the band, and minimize in all other directions. When this image converges, it will be at the exact saddle point. This way gives not only retained information about the shape of the MEP, but also a rigorous convergence to a saddle point.

**Research Methodology**

All calculations were done using the Vienna *Ab initio* Simulation Package (VASP). Electron exchange-correlation energy was treated by Generalized Gradient Approximation (GGA) with the implementation of Perdew and Wang (PW91). The electron-ion interaction was described by the PAW method. The plane wave energy cutoff used was 270 eV. Monkhorst-Pack *k*-point grid of size 10 × 10 × 10 and 3 × 3 × 1 were used for bulk and surface calculations respectively. Primitive lattice vector was employed in the bulk calculations. Geometry optimization were performed using quasi-Newton method and structural parameters were considered as converged when the atomic forces were less than 0.02 eV/Å. Methfessel-Paxton smearing of σ = 0.2 eV was utilized to improved convergence and the corrected energy for σ → 0 was employed.
Calculating Adsorption Energy

The adsorbates of H$_2$S and SH molecules were placed on one side of the studied metal surfaces with the calculated equilibrium orientation. S and H atoms were placed 2 Å above one side of the metal surfaces. During calculation the molecules or atoms were fully relaxed as well as the top two (or three) layers of the studied metal surfaces.

![Adsorption Sites of Bcc Metal Surface](image)

The calculation results were summarized to examine the adsorption site with the most minimum adsorption energy. The post-calculate geometry of the adsorbates were examined as well. The adsorption energy of the adsorbates is calculated using expression of

$$E_{ads} = E_{adsorbate+slab} - (E_{slab} + E_{adsorbate})$$

where $E_{adsorbate+slab}$ is the total energy of the relaxed adsorbate-surface system, while $E_{slab}$ and $E_{adsorbate}$ are the total energy of the relaxed bare surface and gas phase adsorbate respectively. Based on this definition, a negative $E_{ads}$ indicates that the adsorption is exothermic.

The adsorption sites of bcc and fcc metal structures are respectively shown as in Figure 4 and Figure 5. Top site is defined as the site where adsorbate atom is on top of one of the atom’s surface (first layer). Bridge site is defined as the site where adsorbate atom is on the between of two atom’s surface. Hollow site is defined as the site where adsorbate atom is on top of one of the atom’s subsurface (second layer for hcp type and third layer for fcc type). In the case of the adsorbate is a molecule, S atom would be the center of mass.

Calculating Reaction Energy and Activation Energy Barrier of Dissociation Process

H$_2$S dissociation process is divided by three reaction steps as follows.

- $H_2S_{(gas)} \rightarrow H_2S_{(ad)}$
- $H_2S_{(ad)} \rightarrow SH_{(ad)} + H_{(ad)}$
- $SH_{(ad)} \rightarrow S_{(ad)} + H_{(ad)}$
In order to know whether each reaction is favorable, the overall reaction energy \( \Delta E_{\text{rxn}} \) of each reaction is calculated using the expression of

\[
\Delta E_{\text{rxn}} = \sum E_{\text{prod}} - \sum E_{\text{react}}
\]

Where the first and second terms represent the sum of energies of products and reactants, respectively. A negative value of \( \Delta E_{\text{rxn}} \) corresponds to an exothermic reaction.

In order to obtain the reaction path and transition state of \( \text{H}_2\text{S} \) dissociation, CI-NEB method is employed. The initial reactants and final reaction products of dissociation process as earlier described above are required in CI-NEB method. One image point of climbing image nudge elastic band (CI-NEB) method is employed to obtain the transition state and the activation energy barrier of \( \text{H}_2\text{S} \) dissociation. The initial reactants and final reaction products of dissociation process were assumed to proceed via the preferred binding site and the stable near-neighbor site respectively. This way, one image point would be sufficient and reasonable to obtain the transition state. The image was optimized using quasi-Newton optimization scheme until it reached the convergence in which the atomic forces on the system were less than 0.02 eV/Å. Then, the activation energy barrier of the dissociation process can be calculated after the transition state is obtained using the expression of

\[
E_a = E_T - E_I
\]

Where \( E_T \) is total energy of the transition state and \( E_I \) is total energy of the initial state. The activation energy barrier means the energy required to dissociate the bond. The greater the activation energy barrier, the more energy is needed for dissociation to occur.

**Results and Discussion**

**Calculation of Bulk Vanadium and Palladium**

Freeze bulk calculations were done by varying lattice constant value from 2.7 Å to 3.4 Å for vanadium and from 3.7 Å to 4.4 Å for palladium. The true lattice constant is the lattice constant with the most minimum total energy. By plotting and fitting the total energy vs. lattice constant and finding the positive roots value, calculated lattice constant was obtained 2.985 Å and 3.923 Å for vanadium and palladium respectively. These results are in excellent agreement with experimental value of 3.03 Å and 3.883 Å for vanadium and palladium respectively (Kittel, 2005 and Coles, 1956).

![Figure 6. Calculated Lattice Constant of (a) Vanadium and (b) Palladium](image-url)
Optimized Atomic Structure of The Molecules and Pseudomorphic Overlayer

The geometry of H$_2$S and SH molecules were optimized in a large cell of 15Å × 15Å × 15Å. The bond length and bond angle were found to be 1.356 Å and 90.6° respectively, which is in good agreement with the experiment values of 1.328 Å and 92.2°. Similarly, the computed bond length of SH is 1.361 Å, which is in good agreement with the experiment value of 1.345 Å (Chase, 1989).

Figure 7. Optimized Atomic Structure of H$_2$S and SH Molecules

Overlayer structure was constructed by placing Pd adatoms at hollow sites of V(110) surface and optimized by fully relaxing the top three layers. The Pd adlayer adopted the lattice constant of vanadium rather than its own bulk lattice constant, but this was match coherently (pseudomorphic). The optimized structure of Pd/V(110) is shown in Figure 8, where outward relaxation has been found between the first and second layers by $\Delta d_{12} = + 6.2\%$ and between the second and third layers by $\Delta d_{23} = + 4\%$. The Pd–Pd and V–V bond length of 2.59 Å did not change after optimization, and the optimized Pd–V interatomic distance of 2.99 Å amounts to a 13.3% expansion compared to Pd–Pd or V–V bond length.

Figure 8. Optimized Atomic Structure of Pd pseudomorphic Overlayer on V(110) Surface

Adsorption of H$_2$S, SH, S, and H on the Metal Surfaces

The computed adsorption energies and properties of H$_2$S are presented in Table 1. For all studied metal surfaces, the adsorption energy value is negative and S-metal distance shortened from its initial distance. This means H$_2$S molecule is favorable to be attracted rather than repulsed by the studied metal surfaces. The molecule was found to be adsorbed on metal surfaces via its S atom. The top site was found to be the most preferable site for H$_2$S to be adsorbed on Pd(111) and Pd/V(110) surfaces. On top of V(110) surface, top site was also found to be stable. However, it is disfavored by 0.225 eV relative to the hollow site. Fcc and hcp sites of Pd(111) surface were found stable by releasing energy of 0.511eV and 0.466 eV respectively. However, Alfonso reported that by using GGA-PBE method and spin-polarized calculation, H$_2$S was unfavorable to bind at fcc and hcp sites of Pd(111) surface since the molecule moved to the bridge site (Alfonso et al., 2008). In our calculation, this phenomenon occurred in the case of SH adsorption.
Table 1. Adsorption Properties of H$_2$S on Studied Metal Surfaces

<table>
<thead>
<tr>
<th>Surface</th>
<th>Site</th>
<th>$E_{\text{ad}}$ (eV)</th>
<th>$d_{\text{S-Metal}}$ (Å)</th>
<th>$d_{\text{S-H1}}$ (Å)</th>
<th>$d_{\text{S-H2}}$ (Å)</th>
<th>$\angle_{\text{Metal-S-H1}}$ (°)</th>
<th>$\angle_{\text{Metal-S-H2}}$ (°)</th>
<th>$\angle_{\text{H-S-H}}$ (°)</th>
</tr>
</thead>
<tbody>
<tr>
<td>V (110)</td>
<td>top</td>
<td>-0.530</td>
<td>2.50</td>
<td>1.37</td>
<td>1.37</td>
<td>110.2</td>
<td>110.7</td>
<td>92.2</td>
</tr>
<tr>
<td></td>
<td>bridge</td>
<td>-0.030</td>
<td>1.96</td>
<td>1.38</td>
<td>1.38</td>
<td>138.7</td>
<td>129.7</td>
<td>91.6</td>
</tr>
<tr>
<td></td>
<td>hollow</td>
<td>-0.785</td>
<td>1.95</td>
<td>1.40</td>
<td>1.40</td>
<td>114.5</td>
<td>114.7</td>
<td>92.3</td>
</tr>
<tr>
<td>Pd (111)</td>
<td>top</td>
<td>-0.765</td>
<td>2.32</td>
<td>1.37</td>
<td>1.37</td>
<td>99.2</td>
<td>99.7</td>
<td>91.8</td>
</tr>
<tr>
<td></td>
<td>bridge</td>
<td>-0.572</td>
<td>2.04</td>
<td>1.40</td>
<td>1.38</td>
<td>99.5</td>
<td>99.2</td>
<td>91.6</td>
</tr>
<tr>
<td></td>
<td>Fcc</td>
<td>-0.511</td>
<td>1.98</td>
<td>1.39</td>
<td>1.40</td>
<td>103.9</td>
<td>103.8</td>
<td>92.0</td>
</tr>
<tr>
<td></td>
<td>Hcp</td>
<td>-0.466</td>
<td>2.11</td>
<td>1.38</td>
<td>1.38</td>
<td>98.2</td>
<td>102.1</td>
<td>90.6</td>
</tr>
<tr>
<td>Pd/V(110)</td>
<td>top</td>
<td>-0.424</td>
<td>2.50</td>
<td>1.36</td>
<td>1.36</td>
<td>102.7</td>
<td>101.7</td>
<td>91.7</td>
</tr>
<tr>
<td></td>
<td>bridge</td>
<td>-0.212</td>
<td>2.91</td>
<td>1.36</td>
<td>1.36</td>
<td>92.7</td>
<td>92.7</td>
<td>91.6</td>
</tr>
<tr>
<td></td>
<td>hollow</td>
<td>-0.197</td>
<td>2.95</td>
<td>1.36</td>
<td>1.36</td>
<td>93.5</td>
<td>92.0</td>
<td>91.9</td>
</tr>
</tbody>
</table>

Compared to the previous first-principles study, H$_2$S adsorption on preferable site of V(110) surface releases more energy than on Ag(111), Au(111) and Cu(111) as shown in Table 2, suggesting that H$_2$S molecule is adsorbed on V(110) surface stronger than on the other bare metal surfaces (Alfonso et al., 2003). However interestingly, when vanadium is covered by monolayer of palladium metals, its H$_2$S adsorption energy seems to be the weakest compared to its bare Pd(111) and V(110) surfaces and Pd/Cu(111), Pd/Rh(111), Pd/Ag(111), Pd/Au(111) surfaces reported in the previous study (Hyman et al., 2007). It suggests that H$_2$S is less favorable to be adsorbed on Pd/V(110) surface than on its bare Pd(111) and V(110) and another bimetallic surfaces. Adsorption energy of H$_2$S on the preferred binding site of V(110) differs slightly to Pd(111) and Pt(111) by 0.02 eV 0.125 eV respectively, suggesting that V(110) surface is in the same level as the platinum group metals in the association with H$_2$S.

Table 2. Adsorption Energy of H$_2$S (in eV) on Several Bare and Alloy Metal Surfaces (Hyman et al., 2007 and Alfonso et al., 2003)

<table>
<thead>
<tr>
<th>Metal surface</th>
<th>H$_2$S</th>
<th>SH</th>
<th>S</th>
<th>H</th>
</tr>
</thead>
<tbody>
<tr>
<td>Ag(111)</td>
<td>-0.17</td>
<td>-2.34</td>
<td>-3.94</td>
<td>-2.22</td>
</tr>
<tr>
<td>Au(111)</td>
<td>-0.27</td>
<td>-2.23</td>
<td>-3.99</td>
<td>-2.29</td>
</tr>
<tr>
<td>Cu(111)</td>
<td>-0.26</td>
<td>-2.76</td>
<td>-4.75</td>
<td>-2.58</td>
</tr>
<tr>
<td>Pt(111)</td>
<td>-0.91</td>
<td>-3.18</td>
<td>-5.38</td>
<td>-2.80</td>
</tr>
<tr>
<td>PdAg$_3$(111)</td>
<td>N/A</td>
<td>N/A</td>
<td>3.99</td>
<td>N/A</td>
</tr>
<tr>
<td>PdCu$_3$(111)</td>
<td>N/A</td>
<td>N/A</td>
<td>4.47</td>
<td>N/A</td>
</tr>
</tbody>
</table>

It seems in all studied metal surfaces; there are changes in H$_2$S geometry structure either its bond length or angle. In other word, the existence of metal surfaces below the molecule is indeed affecting the molecule’s atomic structure. On the bridge and fcc sites of Pd(111) surface, there is slight difference S-H bond lengths between the first and second fcc sites of Pd(111) surface, but it is negligible since they differ by less than 0.02 Å. Compared to the initial orientation of H$_2$S molecule, there are some changes in metal-S-H angle of all studied metals. In addition, there are also differences metal-S-H angle between the first and second H atoms. This means, the molecule’s orientation above the studied metal surfaces changed during adsorption not only by pitch-rotating but also roll-rotating.
The computed adsorption energies and properties of sulfuhydril are presented in Table 3. Similar to H₂S, SH molecule was adsorbed to the surface via its S atom. SH molecule was found to bind preferably on hollow site of V(110) surface. Bridge site of V(110) surface seems unstable because SH molecule moved from bridge site to the hollow site during calculation. Bridge site of Pd(111) and Pd/V(110) surfaces was found to be the most preferable binding site of SH molecule, which is in excellent agreement with Alfonso’s work (Alfonso et al., 2003). Fcc and hcp sites of Pd(111) were found to be unstable since the SH molecule moved to the bridge site during calculation, which is in contrast with Alfonso’s work. Furthermore, Alfonso reported that top site of Pd(111) was found unstable for SH molecule to bind, which is again in contrast with our result.

Again, SH molecule is adsorbed on V(110) surface with the highest adsorption energy compared to the noble metal surfaces (Ag, Au and Cu) and platinum group metal surfaces (Pd and Pt). SH molecule adsorbed on Pd(111) surface with energy differs by 1.9 eV less than on Pt(111) surface. This places Pd(111) at number two in adsorption energy of SH molecule after V(110) surface. Pd/V(110) surface reduces the adsorption energy up to 2.6 eV compared to V(110) surface. This value is also weaker by 0.9 eV than Pd(111) surface. Overlayer structure is again taking role in weakening adsorption energy.
The computed S and H adsorption energies and the distance from the adsorbate perpendicular to the metal surface are presented in Table 4. Both S and H atoms prefer the same site for each metal surface. Hollow site of V(110) and Pd/V(110) were found to be the preferred binding sites, while for Pd(111), fcc site seems to be the preferred binding site. Both adsorption energies of S and H atoms on Pd(111) surface are in excellent agreement with Alfonso’s work (Alfonso et al., 2003). Compared to all studied metal surfaces, Pd/V(110) surface seems to have the weakest S atom adsorption energy on their preferable sites. In addition, it is also weaker than adsorption energy of PdCu3 alloy and slightly stronger than adsorption energy of PdAg3 alloy as shown in Table 2. This suggests that pseudomorphic overlayer surface is predicted to have a role to prevent sulfur adsorption as the same way as PdAg3 alloy but better than PdCu3 alloy.

Hydrogen adsorption energy was observed different between fcc and bcc metals. Adsorption energy of H atom on preferable site of V(110) surface shows ~0.3 eV stronger than on preferable site of Pd(111). This is as expected that vanadium adsorbs hydrogen more strongly and exothermically than palladium. Furthermore, vanadium is a hydride forming and fast hydrogen adsorbing metal which is possible to cause cracks easily (Matsui, 1984). Even though it is not as strong as palladium, Pd/V(110) surface shows a competitive energy value of hydrogen adsorption, suggesting that such overlayer membrane would be as reliable as palladium membrane in adsorbing hydrogen. Our calculation shows that adsorption energy of Pd/V(110) is weakened by 1.022 eV compared to its bare V(110) surface. This is similar to the previous study reported by Pallassana et al., in which hydrogen is chemisorb on Pd/Re(0001) with chemisorption energy of -2.25 eV, which is weaker by 0.57 eV than its bare Re(0001) surface (Pallassana et al., 1999).

**H₂S Dissociation on the Metal Surfaces**

Reaction energies of all H₂S dissociation reaction steps on studied metal surfaces are presented in Table 5. It shows that all dissociation reaction steps are energetically favorable over V(110) and Pd(111) surfaces. Compared to the noble metal surfaces shown in Table 6, our studied bare Pd(111) and V(110) surfaces have more exothermic reaction energy for each dissociation step. Reaction energies of -2.173 and -2.005 eV are noted as the strongest energy released by V(110) surface to dissociate H₂S and SH molecules respectively.

<table>
<thead>
<tr>
<th>Metal Surface</th>
<th>I. H₂S(gas) →H₂S(ad)</th>
<th>II. H₂S(ad) →SH(ad) + H(ad)</th>
<th>III. SH(ad) → S(ad) + H(ad)</th>
</tr>
</thead>
<tbody>
<tr>
<td>V(110)</td>
<td>ΔErxn (eV)</td>
<td>ΔErxn (eV)</td>
<td>ΔErxn (eV)</td>
</tr>
<tr>
<td></td>
<td>-0.785</td>
<td>-2.173</td>
<td>0.698</td>
</tr>
<tr>
<td>Pd(111)</td>
<td>-0.765</td>
<td>-1.065</td>
<td>0.056</td>
</tr>
<tr>
<td>Pd/V(110)</td>
<td>-0.424</td>
<td>-0.045</td>
<td>2.858</td>
</tr>
</tbody>
</table>

Table 5. Reaction Energy (ΔErxn) and Activation Energy Barrier (Ea) of H₂S Dissociation on Studied Metal Surfaces.
H₂S dissociation on Pd/V(110) was found favorable as well as SH dissociation with a very slight energy released. The third dissociation step on Pd/V(110), which is SH dissociate to S and H atoms, was found unfavorable since its reaction energy was slightly endothermic. In the view point of sulfur poisoning, this is a good indication since the abstraction of S atom from SH molecule on Pd/V(110) surface will face barrier to couple with. The same behavior was also occurred to Pd/Cu(111) surface reported by Hyman et al. as shown in Table 6 (Hyman et al., 2007).

As shown in Table 5, the abstraction of SH and H from H₂S on each studied metal surfaces needs an amount of energy to overcome the activation barrier. This explains that between adsorption and dissociation process there is an energy condition has to be fulfilled. The platinum group metals (Pd and Pt) have similar activation energy barrier that is very slight barrier. Compared to the noble metals shown in Table 6, the activation energy barrier of V(110) surface is larger than Cu(111) but slightly smaller than Ag(111) and Au(111) surfaces. This suggest that the catalytic activity of V(111) in the presence of hydrogen sulfide molecule is as good as Ag and Cu surfaces. As hoped that Pd/V(110) surface has bigger activation energy barrier than its bare Pd(111) and V(110) surfaces do. It is noted that about 3 eV of energy is required in order for reaction of H₂S dissociation to proceed.

The abstraction of S and H atoms from SH molecule on V(110) has a very small activation energy barrier to be achieved before releasing so much energy. This means SH dissociation on V(110) surface is a facile and exothermic process. This phenomenon is similar to SH dissociation on Pt(111) shown in Table 6 which has the same low activation barrier but slight exothermic process. On Pd(111) surface, dissociation of SH molecule also has small activation energy barrier even though it is bigger by 0.127 eV than on V(110) surface. This suggests that SH dissociation on Pd(111) surface is also a facile and slight exothermic process. Pd/V(110) surface interestingly, the slight endothermic reaction energy of SH dissociation is followed by its quite big activation energy barrier. As shown in Table 5. Pd/V(110) surface needs 1.055 eV of energy to overcome the activation barrier and extra energy of 0.151 eV to proceed the reaction.

### Table 6. Reaction Energy (ΔErxn) and Activation Energy Barrier (Ea) of H₂S Dissociation on Several Overlayer Bimetallic Systems and Bare Metal Surfaces

<table>
<thead>
<tr>
<th>Metal surface</th>
<th>H₂S(ad) → SH(ad) + H(ad) ΔErxn (eV)</th>
<th>Eₐ (eV)</th>
<th>SH(ad) → S(ad) + H(ad) ΔErxn (eV)</th>
<th>Eₐ (eV)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Pd/Cu(111)</td>
<td>-0.28 N/A</td>
<td>0.25 N/A</td>
<td>-0.25 N/A</td>
<td>N/A</td>
</tr>
<tr>
<td>Pd/Rh(111)</td>
<td>-0.49 N/A</td>
<td>-0.3 N/A</td>
<td>-0.3 N/A</td>
<td>N/A</td>
</tr>
<tr>
<td>Pd/Ag(111)</td>
<td>-1.1 N/A</td>
<td>-0.72 N/A</td>
<td>-0.72 N/A</td>
<td>N/A</td>
</tr>
<tr>
<td>Pd/Au(111)</td>
<td>-1.15 N/A</td>
<td>-0.69 N/A</td>
<td>-0.69 N/A</td>
<td>N/A</td>
</tr>
<tr>
<td>Ag(111)</td>
<td>-0.15 0.86</td>
<td>0.12 1.06</td>
<td>0.12 1.06</td>
<td>0.40</td>
</tr>
<tr>
<td>Au(111)</td>
<td>0.02 0.72</td>
<td>0.02 0.68</td>
<td>0.02 0.68</td>
<td>0.68</td>
</tr>
<tr>
<td>Cu(111)</td>
<td>-0.80 0.43</td>
<td>-0.60 0.40</td>
<td>-0.60 0.40</td>
<td>0.40</td>
</tr>
<tr>
<td>Pt(111)</td>
<td>-0.85 0.07</td>
<td>-0.79 0.03</td>
<td>-0.79 0.03</td>
<td>0.03</td>
</tr>
</tbody>
</table>
As shown in Figure 10, the more positive energy value at the end point than at the transition state of Pd/V(110) surface indicates that such configuration, where S and H atoms are still bonded at the end point, did not work in determining a good transition state by CI-NEB method. It will be our concern to evaluate the mistake and recalculate a better configuration.

The geometry properties of H$_2$S dissociation at the transition state is presented in Table 7. One that can be learned from this geometry is that repulsion between molecules/atoms. From the table we infer that Pd/V(110) surface gives the highest repulsion to SH molecule and S and H atoms, while Pd(111) surface placed in the lowest repulsion after V(110) surface. Elongation of S-H bond at transition state was noted with range of 0.03 to 1.67 Å. The highest elongation is belong to Pd/V(110) surface.
Table 7. Geometry Properties of The Transition State of H₂S Dissociation on Metal Surfaces

<table>
<thead>
<tr>
<th></th>
<th>(d_{S\text{-Metal}}) (Å)</th>
<th>(d_{S\text{-H}}) (Å)</th>
<th>(d_{S\text{-H}_2}) (Å)</th>
</tr>
</thead>
<tbody>
<tr>
<td>V (110)</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>(H_2S\text{(ad)} \rightarrow SH\text{(ad)} + H\text{(ad)})</td>
<td>2.85</td>
<td>1.39</td>
<td>1.36</td>
</tr>
<tr>
<td>(SH\text{(ad)} \rightarrow S\text{(ad)} + H\text{(ad)})</td>
<td>1.81</td>
<td>1.39</td>
<td>—</td>
</tr>
<tr>
<td>Pd(111)</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>(H_2S\text{(ad)} \rightarrow SH\text{(ad)} + H\text{(ad)})</td>
<td>2.29</td>
<td>1.47</td>
<td>1.38</td>
</tr>
<tr>
<td>(SH\text{(ad)} \rightarrow S\text{(ad)} + H\text{(ad)})</td>
<td>1.74</td>
<td>1.53</td>
<td>—</td>
</tr>
<tr>
<td>Pd/V(110)</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>(H_2S\text{(ad)} \rightarrow SH\text{(ad)} + H\text{(ad)})</td>
<td>2.22</td>
<td>3.03</td>
<td>1.38</td>
</tr>
<tr>
<td>(SH\text{(ad)} \rightarrow S\text{(ad)} + H\text{(ad)})</td>
<td>2.05</td>
<td>2.08</td>
<td>—</td>
</tr>
</tbody>
</table>

Conclusions
We have studied H₂S adsorption and dissociation on V(110), Pd(111), and Pd/V(110) surfaces using a DFT approach to understand the effects of Pd overlayer on V(110) surface. For H₂S adsorption on V(110), Pd(111), and Pd/V(110) surfaces, the molecule is preferably adsorbed on the hollow, top, and top sites respectively with the H atoms up and the S atom lies closest to the metal surfaces. It has been found that addition of Pd layer on V(110) surface lowers the adsorption energy of H₂S molecule by -0.361 and -0.341 eV as compared with that on bare V(110) and Pd(111) surfaces respectively. When the H₂S molecule dissociates into H and S atoms, the S atom is preferably adsorbed on the respective hollow, hollow-fcc, and hollow sites of V(110), Pd(111), and Pd/V(110) surfaces. The adsorption energy of S atom on Pd/V(110) surface is found to be -4.078 eV, which is lowered by -2.603 and -0.985 eV as compared with that on bare V(110) and Pd(111) surfaces respectively.

Through the analysis of minimum energy path by using Cl-NEB method, it is found that of H₂S and SH dissociation reactions on V(110) and Pd(111) surfaces are both energetically favorable. Whereas for Pd/V(110) surface, only the H₂S dissociation reaction is favorable. The activation energy barrier for H₂S and SH dissociations on Pd/V(110) surface are 2.858 and 1.055 eV respectively. The former is higher by 2.16 and 2.802 eV and the latter is higher by 0.998 and 0.871 eV than those on bare V(110) and Pd(111) surfaces respectively.

The above results indicate that Pd/V(110) surface is very effective to hinder adsorption and dissociation of H₂S molecule and S atom and hence sulfur poisoning can be prevented. In addition, it has advantage in absorbing hydrogen molecule with very high permeation coefficient (Wieland et al., 2002). Therefore, Pd overlayer on V(110) is predicted to be a promising catalyst membrane used in water-gas shift reaction technology for hydrogen production.
References


Pallassana, V., and Neurock, M. 1999. Theoretical analysis of hydrogen chemisorption on Pd(111), Re(0001), Pdmet/Re(0001) and Remet/Pd(111) pseudomorphic overlayers. Physical Review B 60, 6146.


